PATENT AND CONFIDENTIAL INFORMATION AGREEMENT (DRAFT)

| TO: Sony Intelligence Dynamics Laboratories In consideration of the allowance or benefintelligence Dynamics Laboratories, Inc. ('voluntarily agree as follows: | fits paid for my services in the | ne course of my internship at Sony facilities and experience at SIDL, I |
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| 1. I understand and agree to disclosother suggestions (whether or not patentable works, made or conceived by me (alone owhich: (a) relate or correspond to the actual of SIDL which at the time of conception are any other actual or anticipated business, resaware of as a result of my internship at SI internship at SIDL; or (b) result directly, or in may do for or on behalf of SIDL; or (c) are contime for which I was paid by SIDL or which |), all confidential information, r jointly with others) during to or anticipated business, researd within the scope of my internst search and development or inv IDL, knowledge of which I want indirectly, from, or are suggested leveloped, tested, improved or | he period of my internship at SIDL ch and development or investigations ship, or which relate or correspond to estigations of SIDL which I become ould not ordinarily have but for my ed by, any work which I have done or investigated, either in part or entirely, |
| 2. I further agree to execute at any invention, confidential information, copyrig SIDL may provide. I will promptly and fully way, including the signing of any and all including giving testimony, without reimburs except for a reasonable payment for the tin obtain, secure and protect for the benefit of Sother proprietary rights for Inventions, copy whether I personally believe such rights to be | ht work or mask work as SID assist SIDL during and subseq lawful papers, taking all lawf sement other than my normal cone involved in the event my in SIDL, at the expense of SIDL, a yright works or mask works in | quent to my internship in every lawful oaths, and doing all lawful acts, ompensation as an employee of SIDL, nternship at SIDL has terminated, to all patents, copyrights, mask works or |
| 3. I agree not to disclose any confibut not limited to: business plans, custom methods, inventories, inventions, processes, areas of expertise), including information reinternship at SIDL, except upon the prior information and proprietary information of Slearn from other employees of SIDL. I will reveal or disclose, sell, use, lecture upon, or SIDL, or authorize anyone else to do these SIDL. This clause shall continue in full force | er lists, drawings, computer patechnological innovations and ceived in confidence by SIDL written consent of SIDL. It SIDL includes matters that I could not, except as SIDL may out publish any confidential inforthings, at any time, either duri | identity of SIDL employees and their from others, either during or after my is understood that such confidential neceive or develop as well as matters I herwise consent or direct in writing, mation or proprietary information of ng or subsequent to my internship at |
| 4. I agree that during the period of my of my internship at SIDL any trade secrets of internship at an employer other than SII writing or other physical form. | or other proprietary information | disclose to SIDL or use in the course a which I may have acquired because is in my memory or embodied in a |
| 5. I recognize that ideas, inventions, my activities while working for SIDL and countries the expiration of my internship period may Accordingly, I agree that such ideas, inventible presumed to have been conceived during terms of this Agreement unless and until I and support. | onceived or made by me, alone have been conceived in significans, confidential information, g my internship at SIDL and a | copyright works or mask works shall are to be assigned to SIDL under the |
| 6. Should I breach any provision of that SIDL may suffer as a result of such brea | this Agreement, I agree that I ch, and SIDL may at any time | shall be responsible for any damage terminate my internship at SIDL. |
| • | to have been made and execut | ed in Japan and any disputes arising |
| | = | |
| Intern's signature | Date —— | Home Address |